Overview of CMOS & Logic Gates

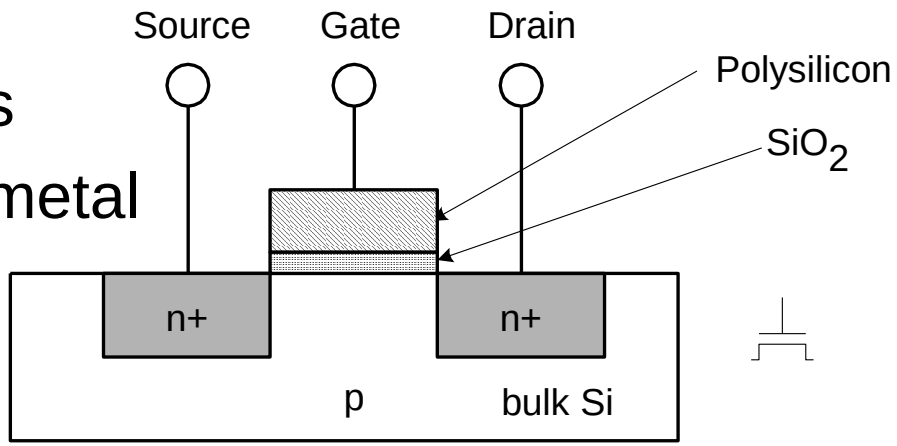
- Introduction to CMOS circuits
- MOS transistor theory, processing technology
- CMOS circuit and logic design

Transistor Types

- Metal Oxide Semiconductor Field Effect Transistors
  - nMOS and pMOS MOSFETS
  - Voltage applied to insulated gate controls current between source and drain
  - Low power allows very high integration
- *Complementary Metal Oxide Semiconductor*
  - Fast, cheap, low power transistors

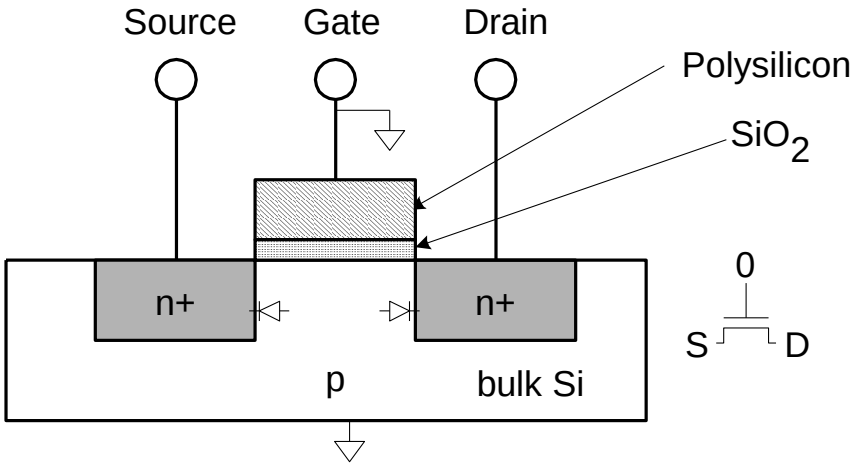
nMOS Transistor

- Four terminals: gate, source, drain, body
- Gate – oxide – body stack looks like a capacitor
  - Gate and body are conductors
  - SiO_2 (oxide) is a very good insulator
  - Called metal – oxide – semiconductor (MOS) capacitor
  - Even though gate is no longer made of metal



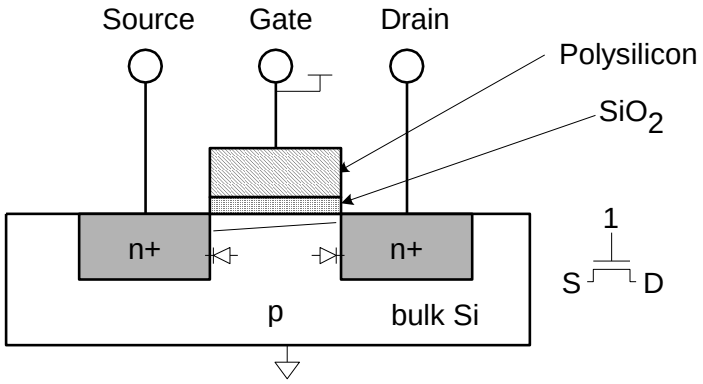
nMOS Operation

- Body is commonly tied to ground (0 V)
- When the gate is at a low voltage:
  - P-type body is at low voltage
  - Source-body and drain-body diodes are OFF
  - No current flows, transistor is OFF



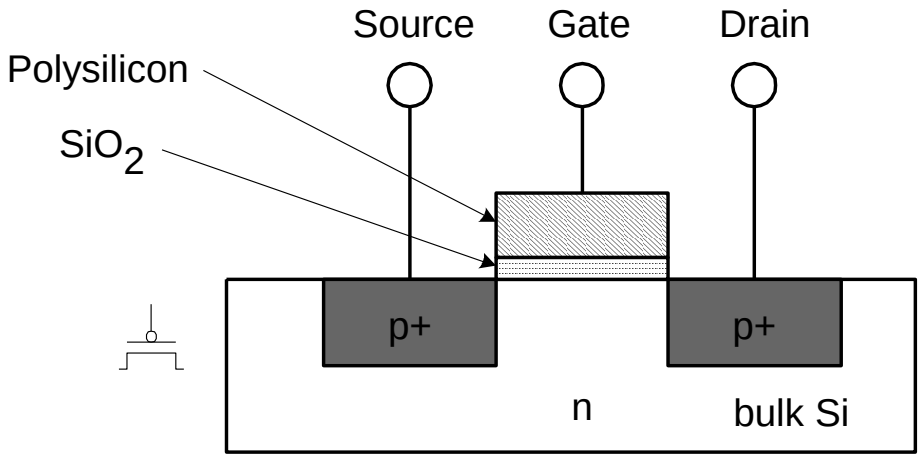
nMOS Operation Cont.

- When the gate is at a high voltage:
  - Positive charge on gate of MOS capacitor
  - Negative charge attracted to body
  - Inverts a channel under gate to n-type
  - Now current can flow through n-type silicon from source through channel to drain, transistor is ON



pMOS Transistor

- Similar, but doping and voltages reversed
  - Body tied to high voltage (V_{DD})
  - Gate low: transistor ON
  - Gate high: transistor OFF
  - Bubble indicates inverted behavior

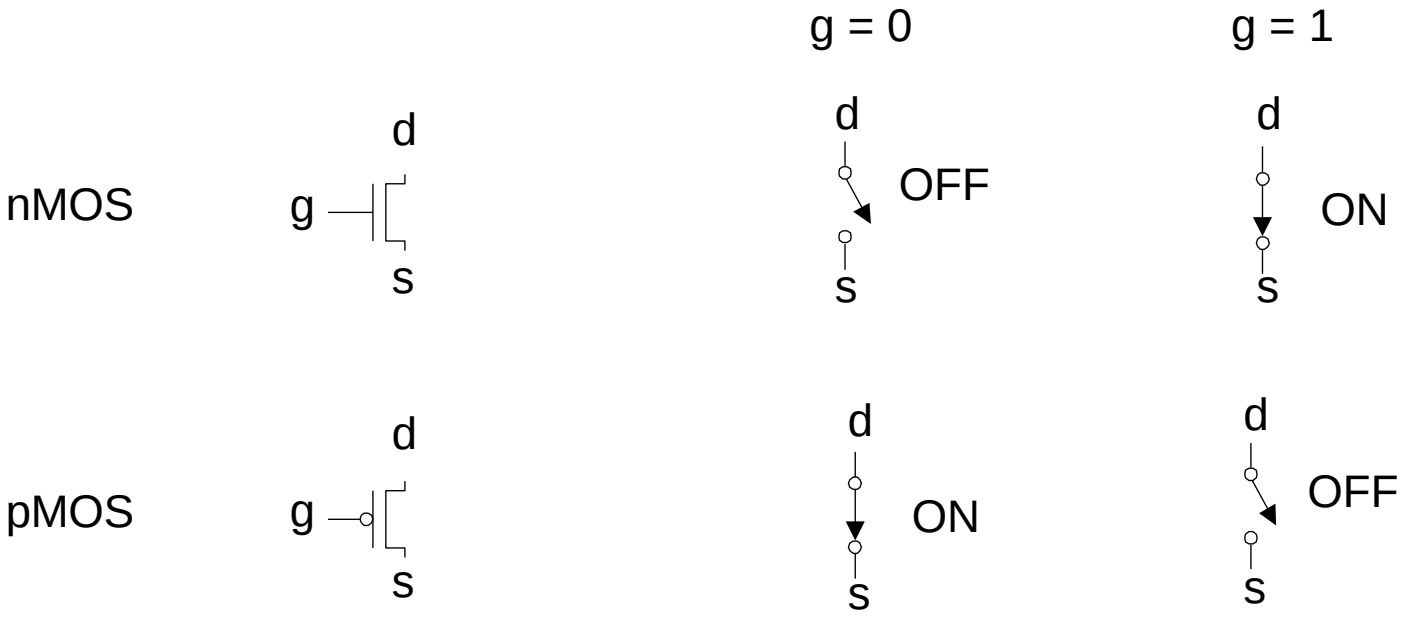


Power Supply Voltage

- GND = 0 V
- In 1980's, V_{DD} = 5V
- V_{DD} has decreased in modern processes
  - High V_{DD} would damage modern tiny transistors
  - Lower V_{DD} saves power
- V_{DD} = 3.3, 2.5, 1.8, 1.5, 1.2, 1.0, …

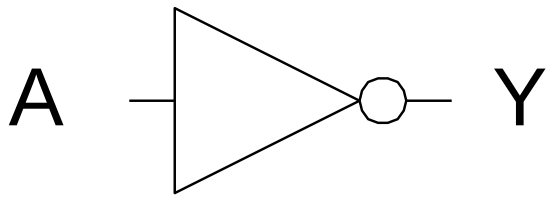
Transistors as Switches

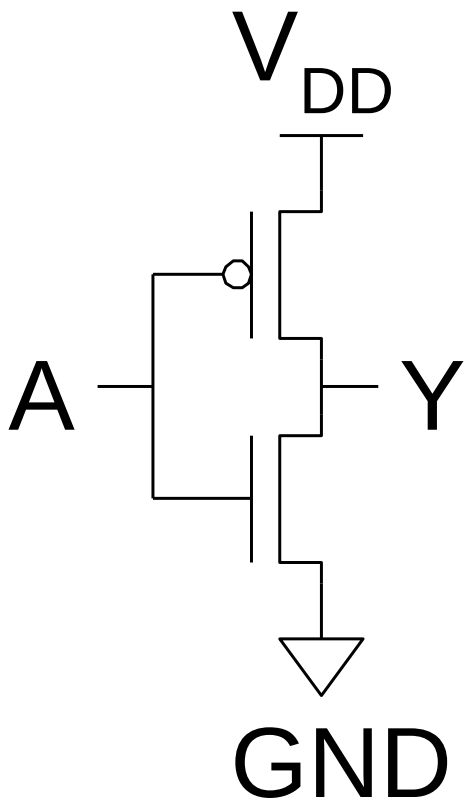
- We can view MOS transistors as electrically controlled switches
- Voltage at gate controls path from source to drain



CMOS Inverter

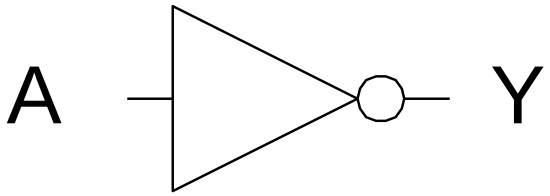
A	Y
0	
1	

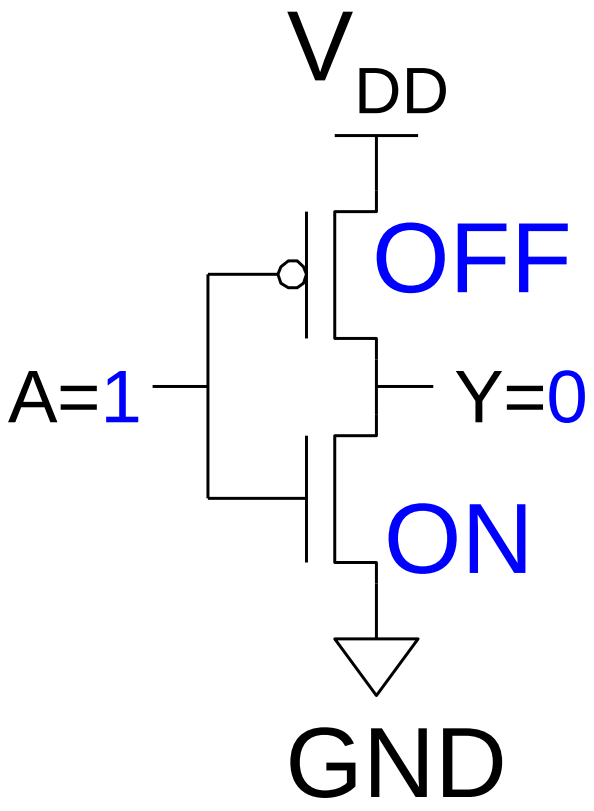




CMOS Inverter

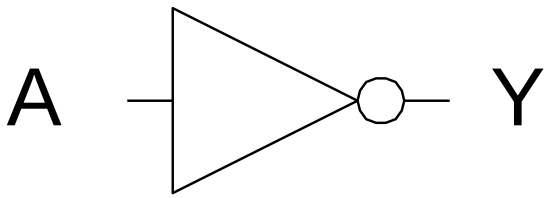
A	Y
0	
1	**0**

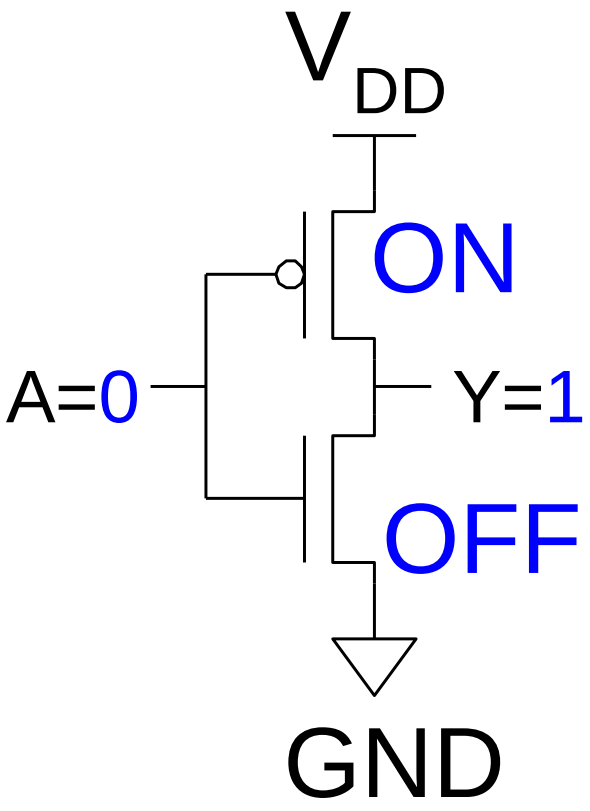




CMOS Inverter

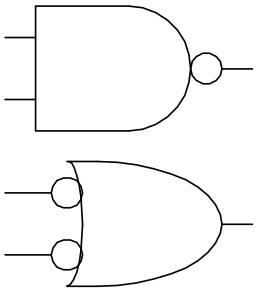
A	Y
0	**1**
1	0

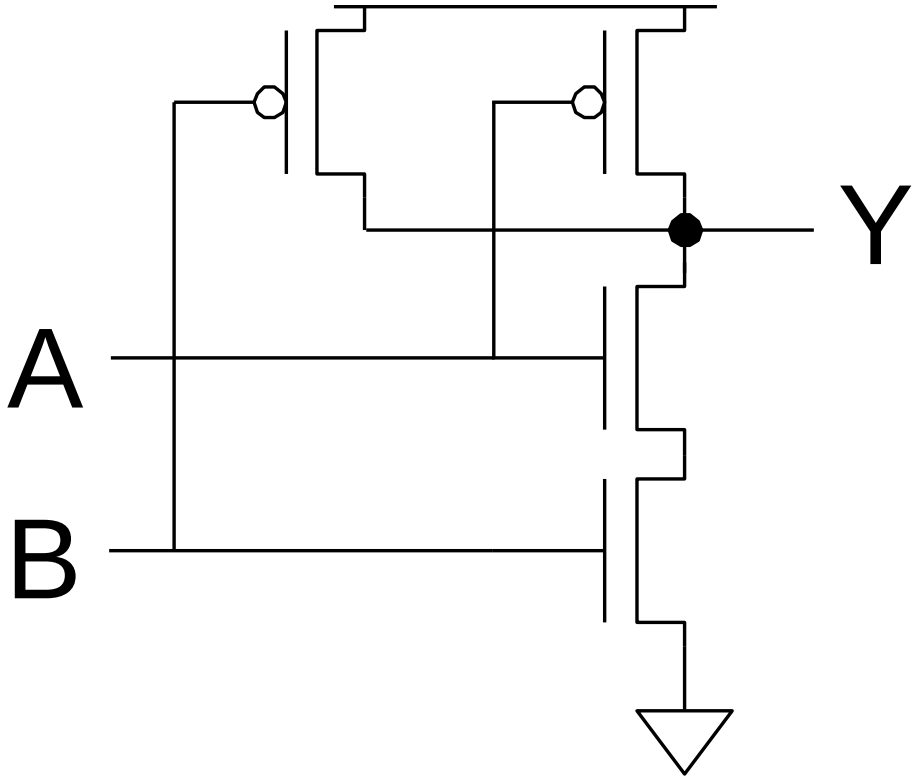




CMOS NAND Gate

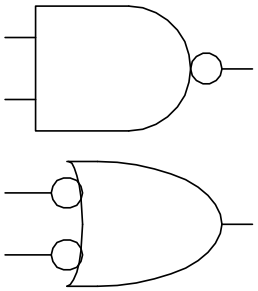
A	B	Y
0	0	
0	1	
1	0	
1	1	

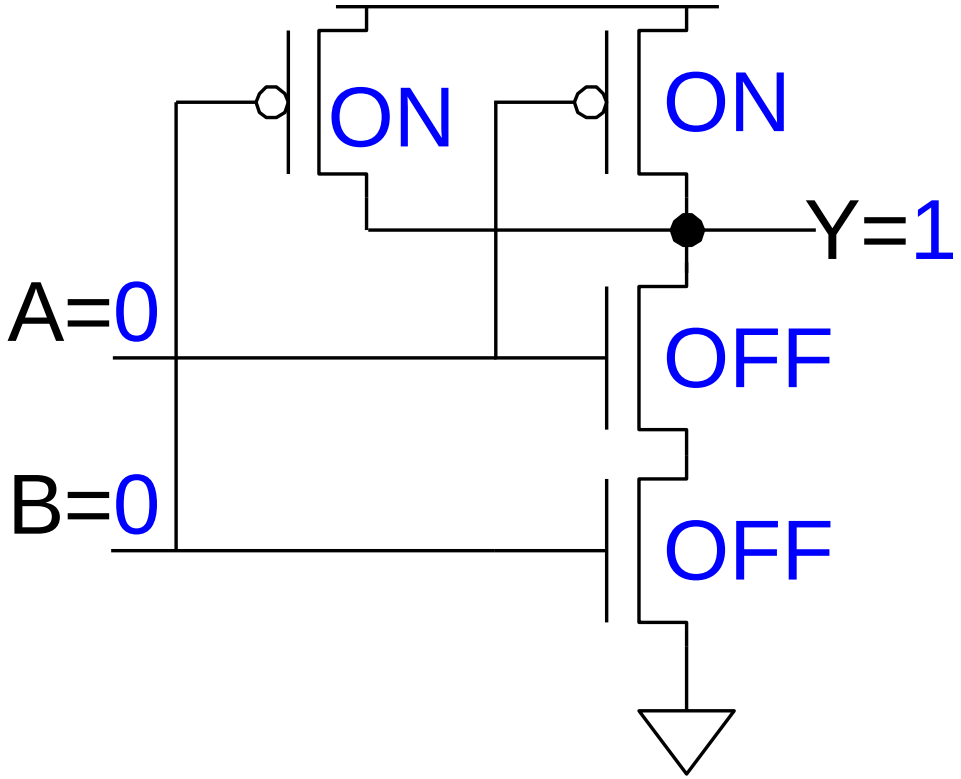




CMOS NAND Gate

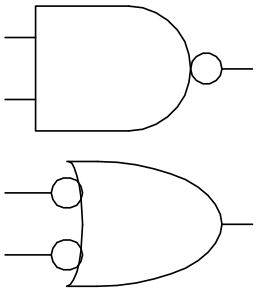
A	B	Y
0	**0**	**1**
0	1	
1	0	
1	1	

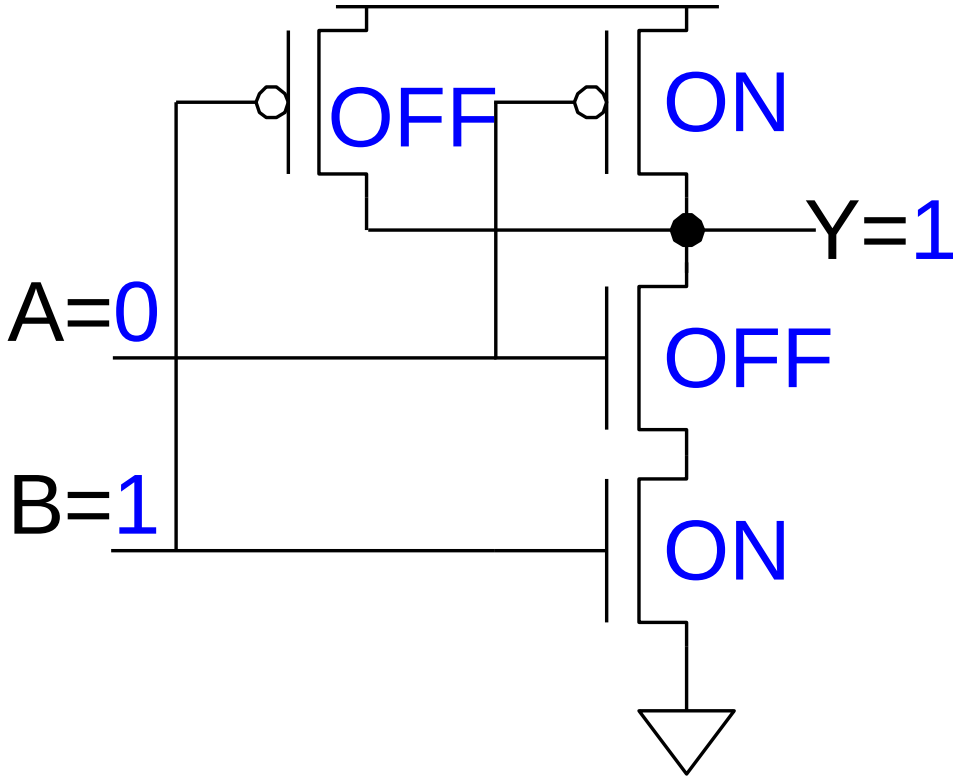




CMOS NAND Gate

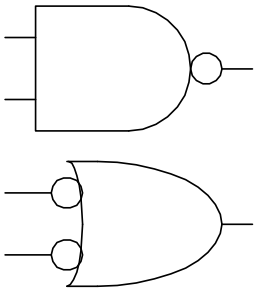
A	B	Y
0	0	1
0	**1**	**1**
1	0	
1	1	

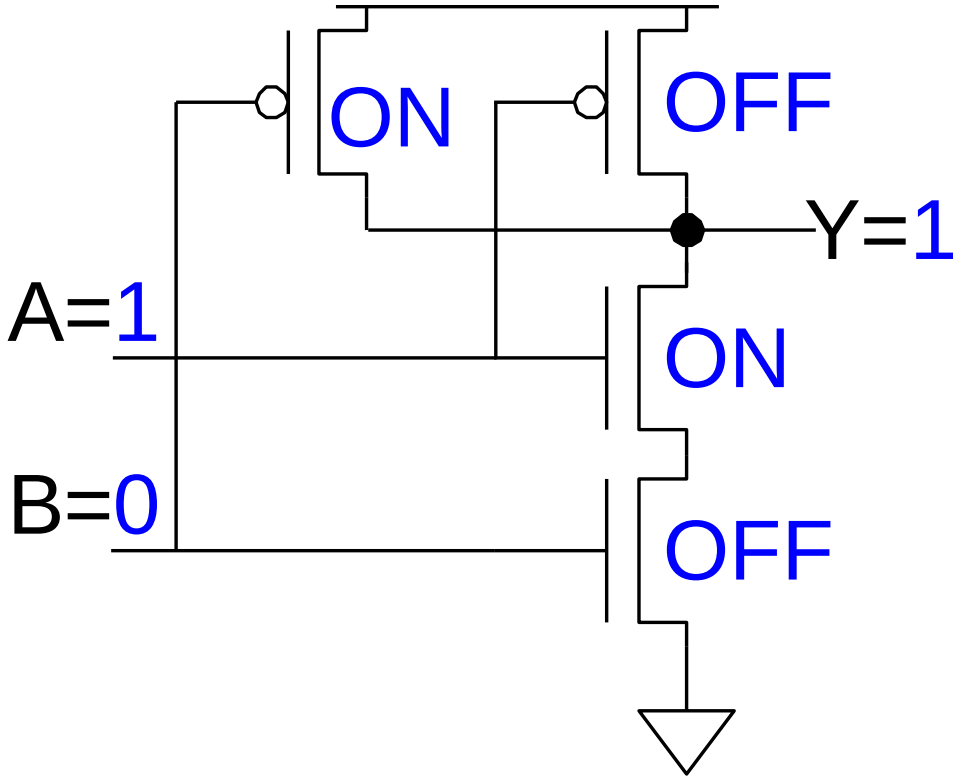




CMOS NAND Gate

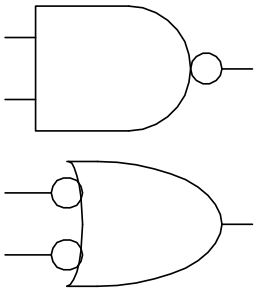
A	B	Y
0	0	1
0	1	1
1	**0**	**1**
1	1	

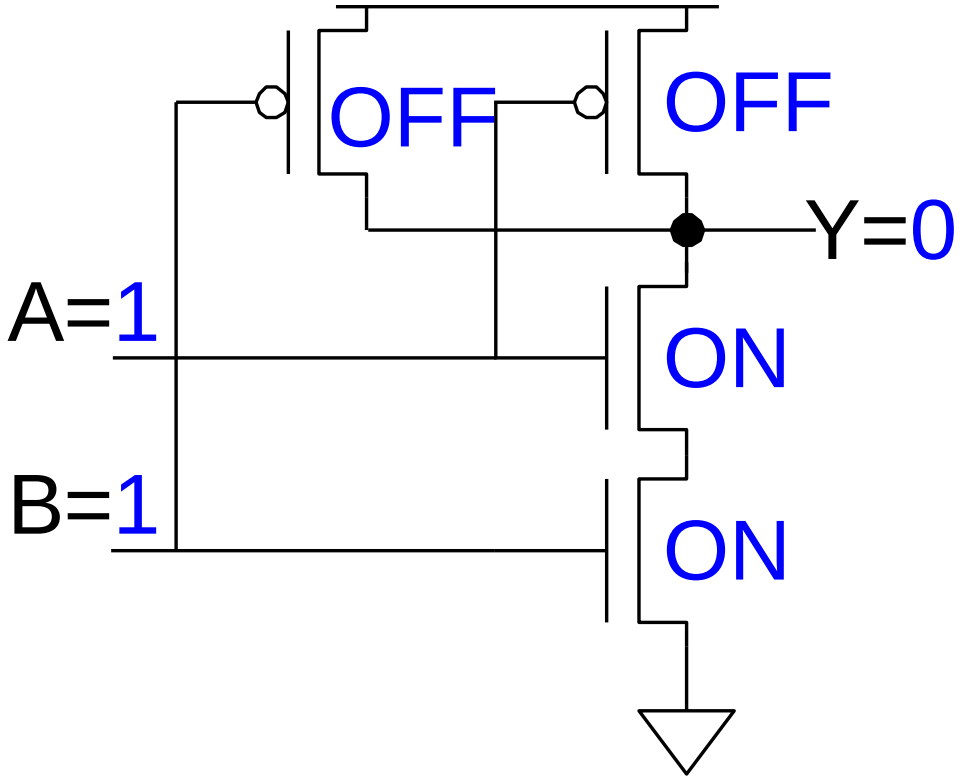




CMOS NAND Gate

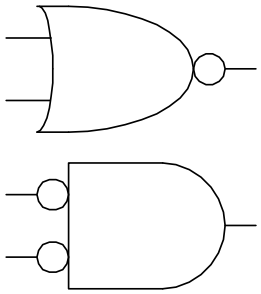
A	B	Y
0	0	1
0	1	1
1	0	1
1	**1**	**0**

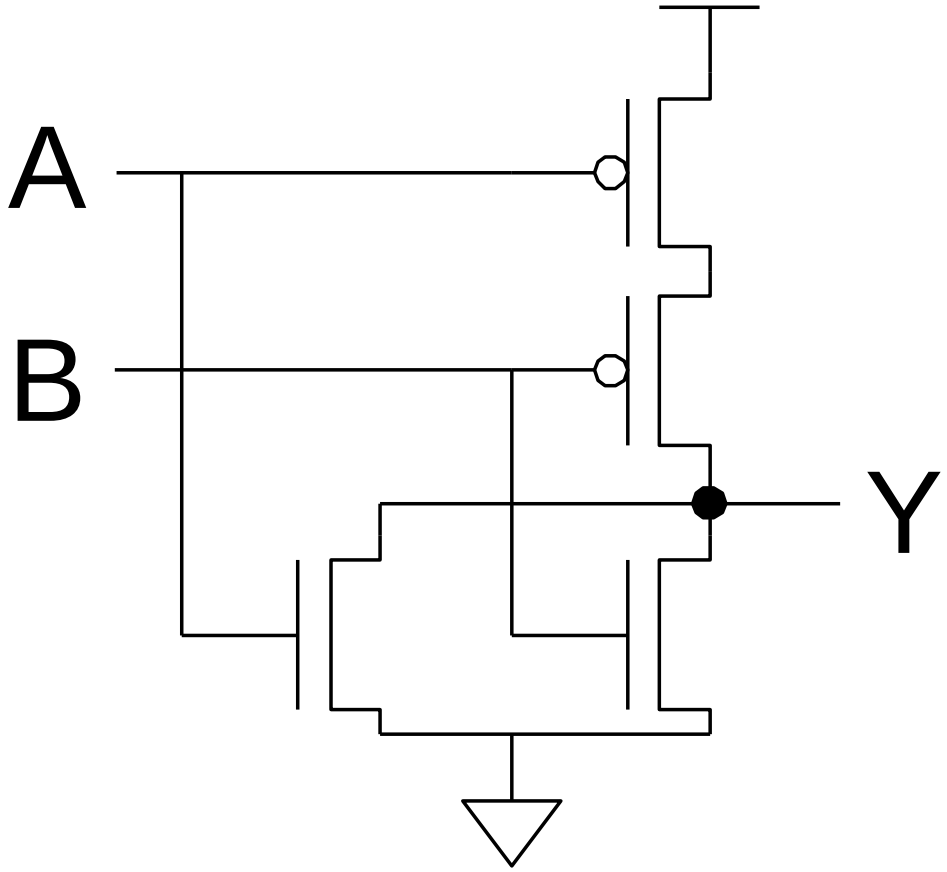




CMOS NOR Gate

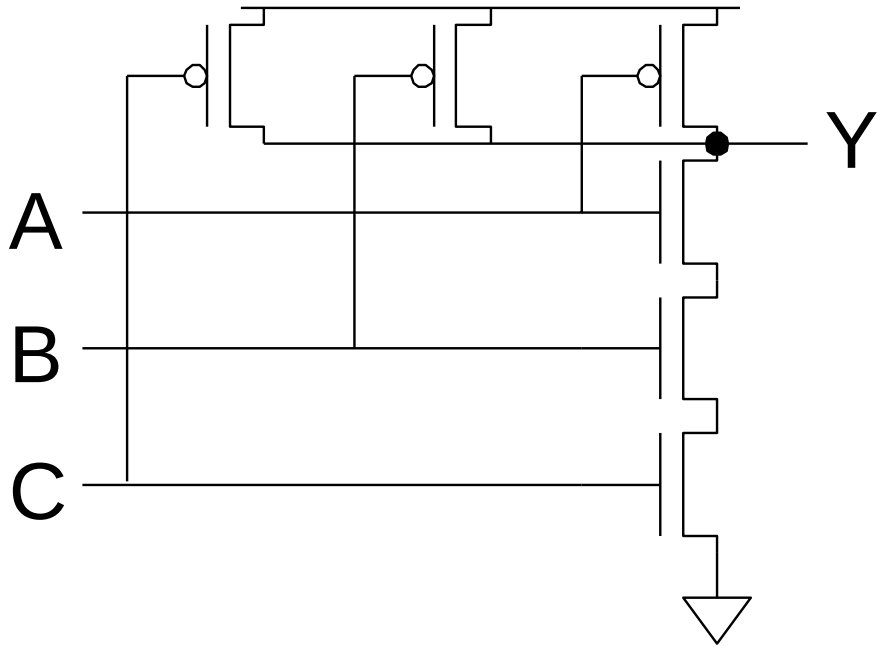
A	B	Y
0	0	1
0	1	0
1	0	0
1	1	0





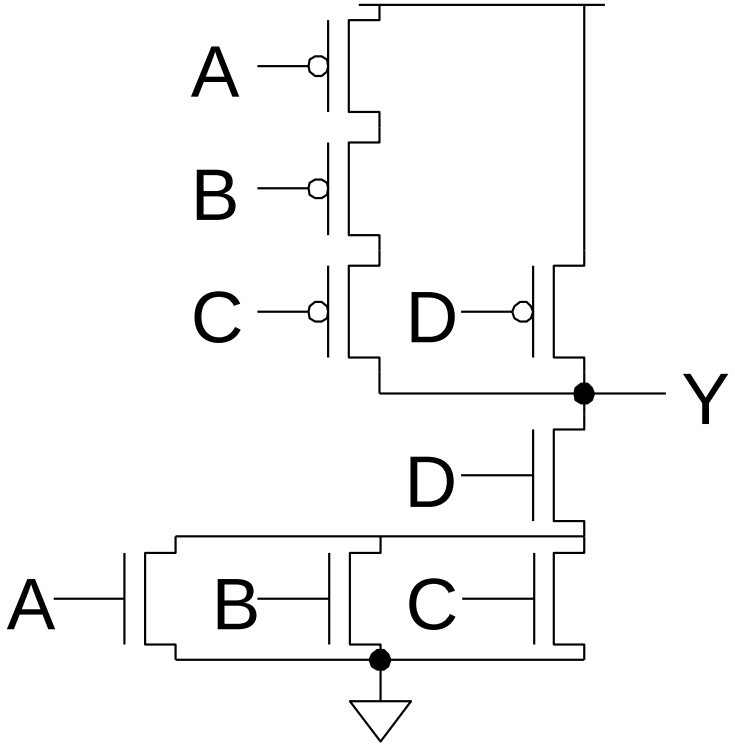
3-input NAND Gate

- Y pulls low if ALL inputs are 1
- Y pulls high if ANY input is 0



Example: O3AI

- $Y = \overline{(A + B + C) \cdot D}$



CMOS Fabrication

- CMOS transistors are fabricated on silicon wafer
- Lithography process similar to printing press
- On each step, different materials are deposited or etched
- Easiest to understand by viewing both top and cross-section of wafer in a simplified manufacturing process

Well and Substrate Taps

- Substrate must be tied to GND and n-well to V_{DD}
- Metal to lightly-doped semiconductor forms poor connection (used for Schottky Diode)
- Use heavily doped well and substrate contacts / taps